

IFW
PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inte Application of:
MATTHIAS KUHN
STEFAN LINGEL

Serial No.: 10/609,096

Filed: June 27, 2003

For: SYSTEM FOR CHEMICAL
MECHANICAL POLISHING
COMPRISING AN IMPROVED PAD
CONDITIONER

Examiner: George Binh Minh Nguyen

Group Art Unit: 3723

Att'y Docket: 2000.105900/DE0291

Customer No.: 23720

RESPONSE TO OFFICE ACTION DATED SEPTEMBER 16, 2004

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

CERTIFICATE OF MAILING
37 C.F.R. 1.8

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the date below:

November 18, 2004

Date

Mary Paul
Signature

This paper is submitted in response to the Office Action dated September 16, 2004, for which the three-month date for response is December 16, 2004.

A fee in the amount of \$230.00 is believed to be due in connection with the present paper. The Director is authorized to deduct such fee, and any other fees required under 37 C.F.R. §§ 1.16 to 1.21, from the Advanced Micro Devices, Inc. Deposit Account No. 01-0365/DE0291. In the event the monies in that account are insufficient, the Director is authorized to withdraw funds from Williams, Morgan & Amerson, P.C. Deposit Account No. 50-0786/2000.105900.

Reconsideration of the application in view of the following amendments and remarks is respectfully requested.

11/26/2004 AWONDAF1 00000029 010365 10609096

01 FC:1201 176.00 DA
02 FC:1202 54.00 DA